

Measuring Dynamic On Resistance in GaN Transistors at MHz Frequencies

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Abstract—Gallium nitride (GaN) transistors are desirable for use in power electronics because of their low resistance and capacitance as compared to silicon devices. However, when switched at high frequencies, GaN transistors experience high dynamic on resistance which is both detrimental and difficult to measure. We propose a technique to measure dynamic on resistance of GaN transistors while exposing them to voltage and current waveforms that are similar to those seen in high-frequency (HF) power converters. The technique can be performed at high frequency while disambiguating loss in the output capacitance (P_{oss}) and can be applied across frequency, temperature, and off-state voltage. The result is a lumped R_{on} value which is easily incorporated into device models to provide a more accurate basis for design, analysis, and simulation of HF converters. We apply this technique to evaluate commercial GaN transistors at 3 MHz and find that dynamic R_{on} is roughly 4-6 times the room-temperature static R_{on} values usually quoted in datasheets, with device-dependent temperature and off-state voltage dependence.

I. INTRODUCTION

Gallium Nitride (GaN) transistors have attracted great attention due to their ability to operate well at higher frequencies than silicon devices. Nevertheless, GaN transistors experience increased effective on-state resistance when switched at high voltage and frequency due to charge trapping in the device [1]–[3]. This increased resistance (often more than 2x with respect to dc) is variously known as current collapse, dynamic on-state resistance, or dynamic R_{on} . Dynamic R_{on} is not commonly reported in datasheets, and how it varies with operating parameters is not well characterized. In addition, characterization techniques for dynamic R_{on} have not been sufficiently developed or agreed upon. Therefore, better measurements of dynamic R_{on} will greatly benefit the design of power electronics incorporating GaN devices and aid in the improvement of the devices.

Some previous efforts have measured dynamic on-state resistance [4]–[10]. The most common approach is to measure both switch current and voltage waveforms during the on state. Since on-state voltage is small and the off-state voltage is large, a voltage clamp must be placed on the switch node to allow for accurate low-voltage measurements. However, some

setups suffer from the clamp’s RC time constant which limits operation speed [9].

Although this approach can be useful to determine the instantaneous dynamic R_{on} during a switching event and may provide useful insights into GaN device physics, it is difficult to convert the data into a lumped R_{on} parameter for modeling and simulation. Furthermore, this method is often measured under hard-switching conditions at low frequencies - an inauthentic environment for GaN switches in high-frequency power converters.

Another approach uses thermal data from a soft-switched high-frequency converter to determine dynamic R_{on} [11], [12]. While this approach provides an authentic high-frequency environment, the power converter may limit reconfigurability for different operating conditions and the reliance on thermal measurements is slow and subject to errors which may be difficult to assess. Moreover, as this technique relies on temperature rise as the measurement signal, it is difficult to determine the temperature dependence of both dynamic R_{on} and the off-state losses P_{oss} .

We propose an approach that is able to measure dynamic R_{on} at megahertz frequencies, using commonly-encountered HF voltage and current waveforms, while varying frequency, off-state voltage, and temperature. This is done by accurately measuring dc power into an unloaded resonant switching circuit operating under zero-voltage switching (ZVS). The measured input power is entirely attributable to losses, which can be designed to be dominated by conduction loss in the transistor. By subtracting the (small) estimated extraneous losses, one can compute an equivalent lumped dynamic R_{on} for a given operating condition.

The remaining sections of the paper include a detailed description of the proposed technique (II), estimation of non-conduction losses (III), and validation of the technique (IV). We then present experimental dynamic R_{on} data for 3 MHz operation across temperature and voltage for GaN Systems, Navitas, and Panasonic devices (V).

II. MEASUREMENT TECHNIQUE

A simplified schematic of the proposed measurement circuit is shown in Fig. 1, with operating waveforms in Fig. 2. When the switch is on, the inductor current ramps up linearly. When

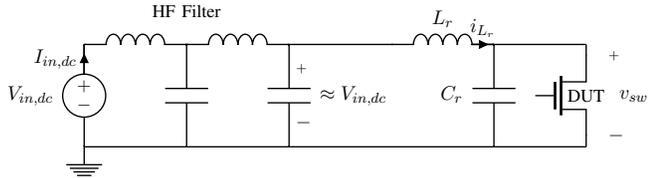


Fig. 1: Simplified circuit diagram for the proposed measurement technique. The device under test (DUT) is operated under zero-voltage switching as indicated in Fig. 2. A nearly dc voltage is provided at the output of the filter, and the input power to the filter can be accurately measured with dc multimeters.

the switch turns off, L_r resonates with the capacitor C_r (in parallel with the device capacitance, C_{oss}), delivering a half-sine pulse of voltage v_{sw} across the device. As the switch voltage returns to zero, the switch is turned back on with ZVS. The magnitude and frequency of the currents and voltage pulses can be designed by the choice of L_r , C_r , the dc input voltage, and the on-time of the FET. It is noteworthy that the on- and off-state waveforms are closely matched to those of some high-frequency converters (e.g. [13]–[17]) and reasonably match a wide variety of soft-switching circuits. Since the variation of dynamic R_{on} across operating conditions is largely unknown, testing in an authentic environment may provide more useful results for circuit designers.

Overall Measurement Strategy:

- 1) Adjust t_{on} and V_{in} to impose off-state voltage pulses at the desired voltage and frequency.
- 2) Measure the dc power P_{in} at the input port of the circuit. This can be done accurately with multimeters.
- 3) Estimate losses not attributable to conduction in the transistor P_{other} and subtract them from P_{in} .
- 4) Measure or infer the switch current $I_{sw,rms}$, and solve for dynamic $R_{on} = (P_{in} - P_{loss,other}) / I_{sw,rms}^2$.

Though these tasks can be summarized briefly, the challenge lies in making the measurements and estimations in steps 2-4 as accurately as possible.

Switching Control: The circuit is controlled by detecting ZVS each cycle to turn the FET on and using a ramp timer to determine the on-time and hence control turn-off (Fig. 3). This is similar to ZVS switching controls used in other applications [18]–[20]. The switch node voltage v_{sw} is stepped-down and compared to a threshold voltage V_{zvs} producing a digital signal Z . When v_{sw} gets close enough to zero, Z transitions to low, which turns the DUT on. At the same time, when Z goes low, the switch S_{ramp} turns off and thus activates an RC -timed voltage ramp v_{ramp} . When v_{ramp} exceeds the threshold V_{tmr} , the digital signal TMR goes high and the circuit turns the DUT off. Turning the device off causes v_{sw} to pulse again, and the process repeats.

By manually adjusting V_{tmr} , the on-time can be varied. By varying t_{on} and V_{in} , the desired pulse voltage V_{pk} and overall frequency can be achieved. For any operating condition, V_{zvs} can be adjusted to achieve ZVS.

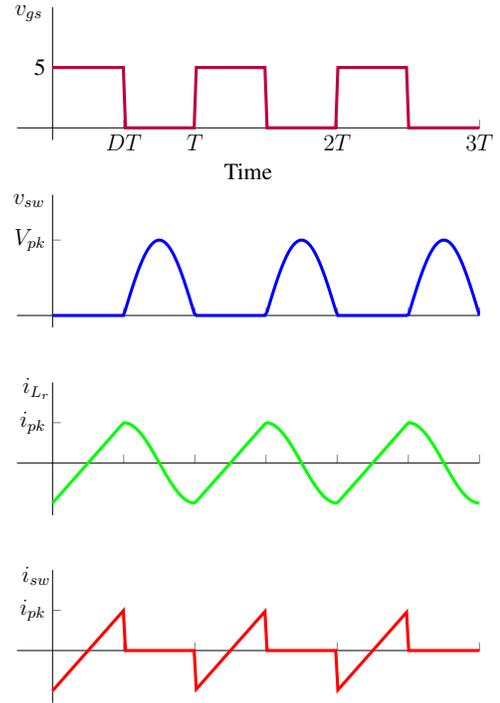


Fig. 2: Circuit operating waveforms showing half-sinusoidal voltage pulses, quasi-sinusoidal inductor currents, and soft-switching conditions that are commonly found in HF converters.

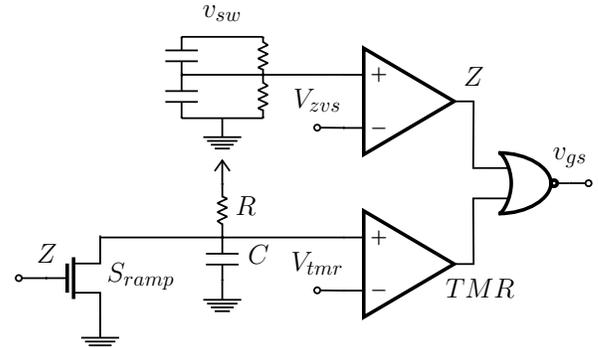


Fig. 3: ZVS detector and timer circuit. FET on-time is set by the RC time constant and the dc V_{tmr} value.

Hardware Setup: To facilitate testing of multiple devices, we divide the test setup into two components. First, a main board contains the filters¹, input power measurement ports, and a microcontroller and DACs that set signals V_{tmr} and V_{zvs} . Second, the transistor board contains the DUT and the HF control circuit (Fig. 3). The main board (Fig. 4) connects to the transistor board (Fig. 5) through a cable. This division allows the transistor board to be easily exchanged to test

¹Since input current I_{in} demand is low but the input voltage V_{in} is high (~ 100 V), some voltage sources may operate in a light-load mode in which bursts of current are supplied at low frequency (~ 10 kHz). A lower frequency filter may be required between the source and the measurement point to prevent source noise from affecting the measurement of P_{in} .

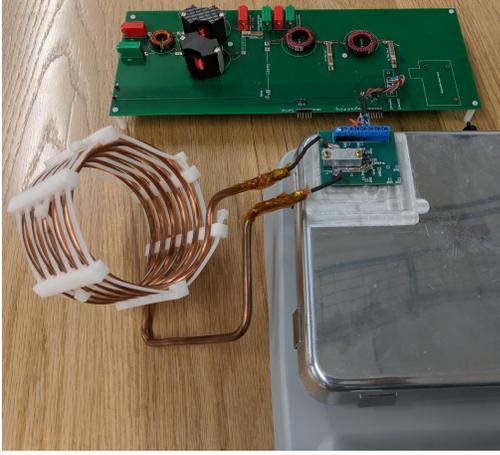


Fig. 4: Overall setup, showing the main board with filters, input power measurement and dc signal generation, as well as a transistor board mounted to the hot plate and the resonant inductor L_r .



Fig. 5: Transistor board mounted to the hot plate, containing the DUT under a mechanical clamp (Fig. 6) as well as the high-frequency ZVS detection and timing circuitry.

different devices, and it facilitates mounting the transistor board to a hot plate for temperature control. Only dc signals are sent from the main board to the transistor board, including input voltage, logic supply V_{cc} , and control reference voltages. Analog voltages are filtered at the comparator inputs to prevent interference. All high frequency signals (e.g. v_{gs} or stepped-down switch voltage $v_{sw,step}$) are contained on the transistor board and are run through short traces.

Temperature Control: We control device junction temperature T_j in order to determine the effects of temperature on dynamic R_{on} . This is done by heat-sinking the device to a hot plate through a low thermal resistance path as shown in Figures 6-7. Using an aluminum hot plate with high thermal conductivity, and with typical dissipation values in our system, we can assume that the case temperature of the device is very close to that of the hot plate. The temperature at the device junction is then the hot plate temperature T_h plus a small ΔT_{jc} owing to the non-zero thermal resistance from the junction to

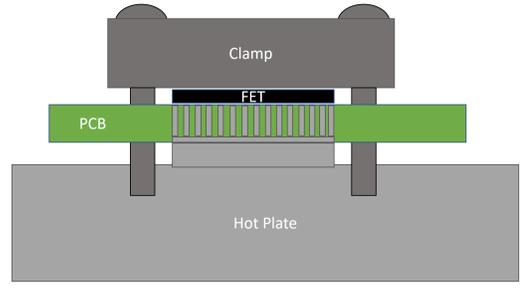


Fig. 6: Side view of thermal control setup. The FET's source pad is via-farmed to the bottom layer of the PCB which makes thermal contact with the hot plate through an aluminum pedestal (machined flat, with thermal grease applied at each junction). A clamp is also screwed on top of the FET, through the PCB, and into the hot plate to provide even pressure.

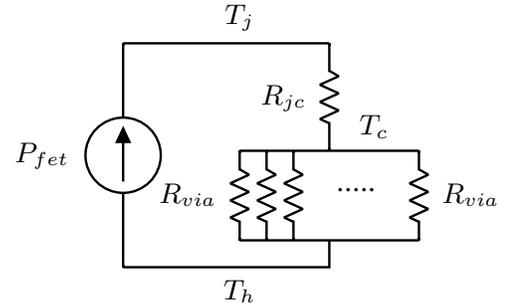


Fig. 7: Thermal model of the thermal control setup. The hot plate temperature T_h is controlled, and heavy via-farming ensures a low thermal resistance connection from the hot plate to the device case (T_c) and junction (T_j). In the prototype system, the thermal resistance from device case to hotplate is kept below ~ 1 $^{\circ}\text{C}/\text{W}$.

	R_{jc}	P_{fet}	ΔT_{jc}	% Error ($\frac{\Delta T_{jc}}{80^{\circ}\text{C}}$)
PGA26E19BA	1.9 $^{\circ}\text{C}/\text{W}$	2.35 W	4.46 $^{\circ}\text{C}$	5.56 %
NV6131	2.2 $^{\circ}\text{C}/\text{W}$	2.21 W	4.86 $^{\circ}\text{C}$	6.08 %
GS66504B	1.0 $^{\circ}\text{C}/\text{W}$	2.20 W	2.20 $^{\circ}\text{C}$	2.75 %

TABLE I: Breakdown of expected errors between junction temperature and case temperature T_c , taken from measurements at $T_c = 80$ $^{\circ}\text{C}$ and $V_{pk} = 400$ V. It can be seen that there are small discrepancies between T_j and T_c ; case temperature control is effectively junction temperature control for purposes of testing across a wide range of temperatures.

the case (Table I). With an appropriately-designed via farm to an exposed copper pad on the reverse side of the PCB, this thermal resistance can be made sufficiently small to be neglected.

To validate this approach, we model the junction-to-case thermal resistance according to the datasheet values, which are about 1–2 $^{\circ}\text{C}/\text{W}$. We model a single via has having $R_{via} = 37.4$ $^{\circ}\text{C}/\text{W}$ [21]. Assuming 100 vias in parallel, we obtain an effective case-to-hot plate resistance of

$R_{ch} = 0.37^\circ\text{C}/\text{W}$, for a total junction-to-plate thermal resistance of approximately $2.5^\circ\text{C}/\text{W}$. With 2 W of loss in the FET (for example), the expected temperature difference from the junction to the hot plate is a negligible 5°C .

III. OTHER LOSS ATTRIBUTION

Given the simplicity of the circuit, the total losses P_{in} can be ideally attributed to only a few sources, namely conduction loss in the FET P_{cond} and other losses including losses in the resonant inductor P_{lr} , in the FET output capacitance's P_{oss} [11] [12], in the filter inductors P_{filter} , and in the ZVS detector voltage divider P_{zvs} . By design, the non-conduction losses P_{other} should be as small as possible; nevertheless, their actual losses can be estimated and subtracted from P_{in} before computing dynamic R_{on} . Most losses are amenable to accurate estimation; we expound on the major contributors of the loss below, in order of decreasing significance. In doing so, we note that a limitation of the proposed technique is that all unidentified loss sources (or under-represented losses) are construed as additional conduction loss owing to dynamic Rds-on. Thus, it is important to account for other loss sources as accurately as possible. In particular, the design or selection of the passive components in the system, especially L_r , is crucial to obtaining precise measurements of dynamic R_{on} . See Appendix A.

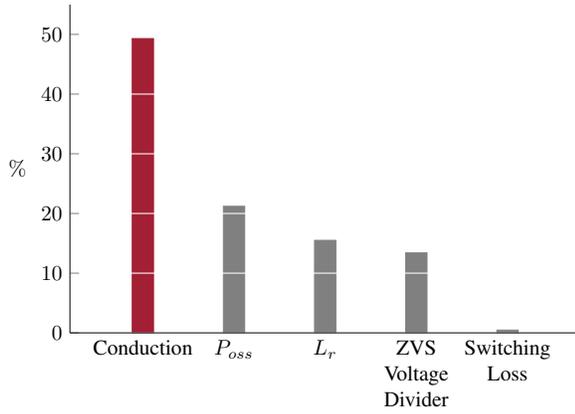


Fig. 8: Typical breakdown of estimated losses' contribution to total loss (%) based on measurements under 400V V_{pk} at 3 MHz on a Panasonic FET (PGA26E19BA). It is important that P_{cond} represent a large fraction of the overall loss to prevent errors in estimating P_{other} from impacting the results.

C_{oss} Losses (P_{oss}): The loss associated with the output capacitor of the DUT (P_{oss}) can be high since the transistor terminals experience high-voltage pulses at high frequency; this loss mechanism is known to be significant at high frequencies in GaN devices and some Si devices. In some cases, these losses are ohmic in nature, while in others the losses are hysteretic or have even more complex relationships [11], [12]. This loss can be difficult to disambiguate from conduction loss since both occur within the FET. Nevertheless, one means to disambiguate P_{oss} from conduction loss is by connecting a second always-off transistor S_2 in parallel to the DUT and

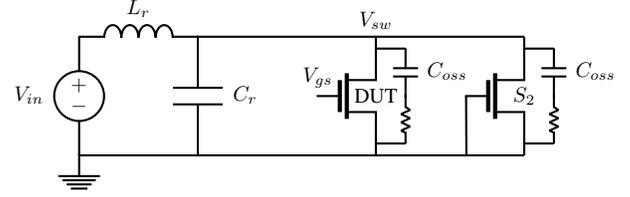


Fig. 9: Method for extracting P_{oss} loss by adding a second always-off transistor (filters not shown). For the same experiment with this setup, the additional loss is wholly attributable to P_{oss} .

using the additional loss imposed by the second device as an estimate of P_{oss} , similar to [11], [12].

Because S_2 is always off, the operating waveforms shown in Figure 2 are not significantly changed (recall that C_r dominates the switch node capacitance by design, so the added C_{oss} of the second device does not significantly affect the operating waveforms; if it does, then the resonant capacitance can be slightly adjusted to compensate for this). P_{oss} can be estimated by performing power output measurements twice: once *without* S_2 in place, and once *with* S_2 . The difference in FET loss in the two cases is attributed to P_{oss} . Note that this estimation technique assumes that P_{oss} of an always-off device is the same as that of a device that switches at high frequency.

Resonant Inductor Loss: The resonant inductor L_r accrues loss P_{lr} as current flows through its equivalent ac resistance R_{lr} . P_{lr} is estimated from the measured rms inductor current $I_{lr,rms}$ and the equivalent resistance of the inductor at the operating frequency R_{lr}^2 . The inductor current is captured on an oscilloscope and the measured inductor current is used to obtain $I_{lr,rms}$. The resonant inductor loss can then be calculated as $P_{lr} = I_{lr,rms}^2 R_{lr}$.

It is important to estimate P_{lr} as accurately as possible since P_{lr} is expected to be one of the most significant contributors to P_{other} . We use a large air-core structure to achieve a high-Q inductor with linear resistance, which keeps P_{lr} both low and predictable. For more details on designing L_r , see Appendix A.

Voltage-Divider Loss: The switch voltage is monitored in order to obtain ZVS (see Fig. 3). This is done by stepping down the voltage through a voltage divider, which accrues loss. This loss is calculated straightforwardly as $P_{zvs} = V_{sw,rms}^2 / R_{step}$, where R_{step} is the total resistance of the divider. $V_{sw,rms}$ may be calculated from the switch voltage as measured on an oscilloscope.

Turn-on and Turn-off (Transition) Loss: The loop containing the resonant capacitor and the FET contains some parasitic inductance L_p . During every turn-on/turn-off period, L_p is magnetized/demagnetized and dissipates loss in the process.

²To avoid accidentally including probe losses, which can be significant at high frequency, measurement of input power should only be taken with no voltage/current probes attached to the system. Probes are then attached to measure e.g. I_{lr} and v_{sw} .

The turn-on and turn-off losses are calculated equivalently as $P_{ton} = P_{toff} = f \frac{1}{2} L_p I_{tran}^2$, where I_{tran} is the instantaneous current through the device during a transition event. We infer I_{tran} from the measurement of the resonant inductor current. Assuming $L_p = 1$ nH, calculations at 3 MHz show that transition losses account for a small portion (0.47%) of total losses (Figure 8). In many cases, it could be ignored.

We need not consider any turn-on overlap or capacitive discharge loss since the circuit achieves ZVS. Overlap turn-off loss can also be ignored due to the strong snubbing effect of C_{oss} and C_r .

IV. VALIDATION

To validate the proposed approach, we performed FET loss measurements across various voltages and verified them as plausible against thermal measurements. For example, we performed thermal resistance measurements on a Panasonic device (PGA26E19BA) by setting v_{gs} to zero and passing dc current from the source to the drain *without* heat-sinking the transistor board. Measurements of I_{sd} , V_{sd} , and ΔT showed a measured thermal resistance of 35 °C/W (case ΔT for given dissipation).

We then performed a dynamic R_{on} test (at 3 MHz and 400 V_{pk}), again without heat-sinking the device. The experiment produced a calculated FET loss ($P_{cond} + P_{oss}$) of 1.6 W during operation. We simultaneously recorded the temperature of the FET case with a thermal camera, which was ≈ 86 °C. Letting ambient temperature $T_A = 25$ °C, we expect the temperature of the FET to be: $T_A + 35$ °C/W $\cdot 1.6$ W = 81 °C which is reasonably close to the measured value of 86 °C. We performed several of these tests across various voltages and achieved very similar results. This verifies the accuracy of our loss modeling and adds confidence to our FET loss calculations.

V. RESULTS

In this section, we report experimental results of dynamic on-state resistance of commercial GaN FETs from GaN Systems, Navitas, and Panasonic. For each device, data was recorded at 3 MHz overall frequency, for two different peak off-state voltages ($V_{pk} = 200$ V and 400 V), at several temperatures (room temperature, 80 °C, and 120 °C) as explained in Sec. II. As measurements were performed at the same frequency for similar devices, the same resonant inductor was used while the resonant capacitor value was adjusted slightly.

Results from each device are shown in Figs. 10–12, with dynamic R_{on} normalized to the datasheet value at 25 °C. The most striking feature of the results is the high overall value for dynamic R_{on} , roughly 4-6 times the room-temperature static R_{on} value on the datasheets. This result is consistent with findings by other research groups [11] that reported FET conduction loss multipliers ranging from 2-3 over their datasheet values at elevated temperatures.³ The switching environment

³ [11] does not report operating temperatures, but reasonable elevated temperatures can cause dc resistance to increase by 1.5-2 times.

between this work and that of [11] are somewhat similar (soft-switched at MHz frequencies) and any discrepancy between the findings may be attributable to differences in v_{sw} voltage and i_{sw} current waveforms. Nevertheless, the results agree that the dynamic R_{on} values are substantially higher than static R_{on} , even when temperature is taken into account.

In general, dynamic R_{on} increases with peak switch voltage as seen in Figs. 10–12. This result is consistent with previous findings [5], [6], [22]. This is most likely due to high electric fields in the channel forcing electrons into trap states, causing dynamic R_{on} to increase.

The results in Figs. 10–12 also allow us to see how dynamic R_{on} varies with operating temperature. In particular, the results suggest that dynamic R_{on} is not a strong function of temperature for these devices. This may be the result of two conflicting phenomena: 1) as temperature increases, electrons in trap states are energized and more readily escape the traps, decreasing dynamic R_{on} , and 2) as temperature increases, ohmic resistance increases which increases the apparent R_{on} . The relative strength between these two competing effects may vary across devices, voltages, and temperature ranges.

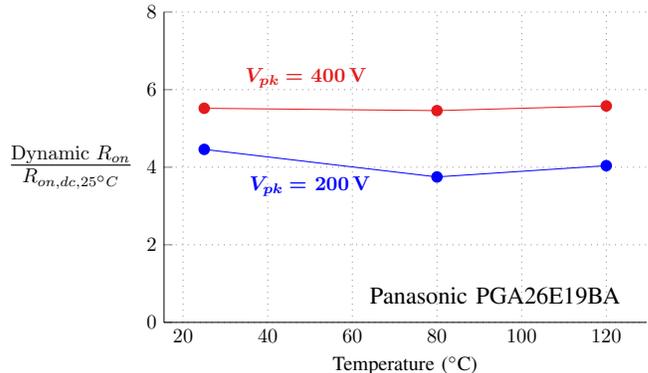


Fig. 10: Thermal sweep across 20, 80, and 120 Celsius show that dynamic R_{on} isn't a strong function of temperature. Measurements were done at 3 MHz on a Panasonic FET with static $R_{on} = 140$ m Ω at 200V and 400V V_{pk} .

VI. CONCLUSION

We proposed a technique for measuring losses in GaN transistors at high frequency. This approach is capable of disambiguating dynamic R_{on} losses and P_{oss} losses, and can be performed at a variety of frequencies, off-state voltages, and temperatures. Finally, the voltage and current waveforms imposed upon the DUT authentically resemble those of many high-frequency converters.

We also contribute some loss data for extant commercial GaN transistors. In general, the losses in the GaN FETs presented are significantly higher than expected from the listed R_{on} , even when accounting for temperature rise and other losses like P_{oss} . The tested devices show an increasing dependence of dynamic R_{on} with off-state voltage, as is expected. The dependence on temperature is less severe than would be expected from the static R_{on} temperature dependence.

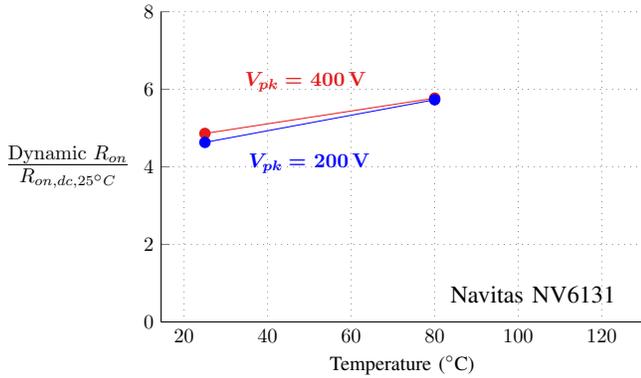


Fig. 11: Thermal sweep across 20 and 80 Celsius show that dynamic R_{on} isn't a strong function of temperature. Attempts at measuring at 120 Celsius caused the FET to fail. Measurements were done at 3 MHz on a Navitas FET with static $R_{on} = 135m\Omega$ at 200V and 400V V_{pk} .

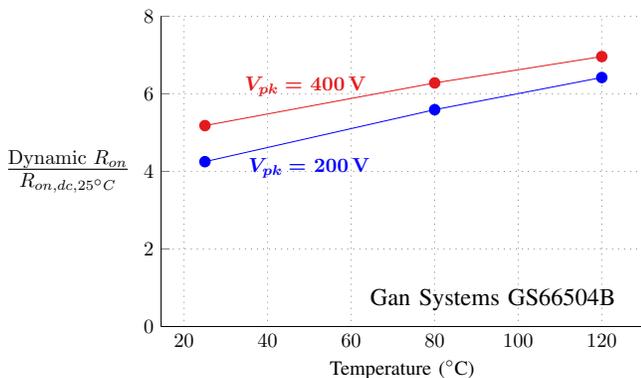


Fig. 12: Thermal sweep across 20, 80, and 120 Celsius show that dynamic R_{on} increases with temperature with decreasing margin. Measurements were done at 3 MHz on a GaN Systems FET with static $R_{on} = 100m\Omega$ at 200V and 400V V_{pk} .

Given the importance of accurate loss predictions for design, simulation, and modeling - along with the difficulty of measuring dynamic R_{on} , the proposed technique offers a solution to characterizing these significant discrepancies.

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APPENDIX A IMPLEMENTATION DETAILS

The final component design and selection are summarized in Table II. The choice of resonant components is particular

Resonant Inductor		Resonant Capacitor	
L_r	2.5 μ H	C_r	500 pF
Turn Diam.	0.25 in	C_r Type	COG 1 kV
Turn Spacing	0.30 in		
Turns	5		
L_r Diam.	4.53 in	Important ICs	
L_r Length	2.45 in	Comparator	ADCMP601
Q	680	DAC	LTC2602

TABLE II: Implementation details for the experimental setup for 3 MHz operation

to 3 MHz operation. The filter and IC component selection is not strongly a function of operating conditions; these components are found on the "main board" which is used in common across multiple devices and operating points.

Design of Resonant Components: In this approach, passive component design and selection are crucial to obtain high precision dynamic R_{on} measurements.

The resonant components L_r and C_r in Fig. 1 form a resonant tank. The component values must be chosen to satisfy a variety of constraints, including providing red pulse voltage peak and duration (or, equivalently, resonant frequency). They must also be chosen or designed such that the required current to generate the voltage pulse does not violate switch ratings but provides sufficient conduction loss to make P_{sw} the majority of the loss. An additional constraint is ensuring that C_r is large enough to be the dominant capacitance at the switch node (i.e. $C_r \gg C_{oss}$).

While the resonant component values influence the above metrics, the inductor quality factor Q (i.e. the specifics of its design) matters as well.⁴ Inductor loss as a fraction of total loss depends both on the required current (determined by the L_r , C_r values) and the inductor's equivalent resistance (determined by its Q). The achievable quality factor is itself a function (albeit not analytically defined) of the inductor value, and this coupling makes optimization difficult.

To aid in design, we wrote a program to check various L_r and C_r pairs (for given inductor quality factor) and to highlight those combinations that satisfy all the constraints. The program output is a color map in the L_r , C_r plane, with acceptable and unacceptable regions (e.g. Fig. 13). A generalized control-flow diagram of the program is provided in Fig. 14.

For a given L_r and C_r , we calculate the required on-time and input voltage to achieve the desired pulse voltage and overall frequency. To achieve the correct overall period, the on-time is chosen to be

$$t_{on} = \frac{1}{2} \left(T - \frac{\pi}{\omega_r} \right) + \sqrt{\left(\frac{\pi}{\omega_r} - T \right)^2 - \frac{16}{\omega_r}} \quad (1)$$

⁴The resonant capacitor quality factor Q_C may be important in principle; nevertheless, low-loss NP0/COG ceramic, porcelain, and mica capacitors in the 500–5000 pF range are readily available with quality factors above 1000.

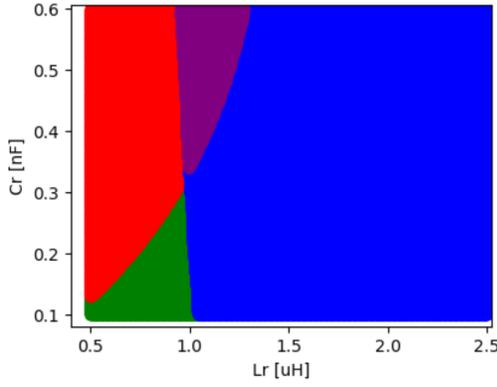


Fig. 13: Example program output categorizing L_r , C_r space into regions of varying acceptability. Green areas correspond to L_r and C_r pairs that satisfy all constraints. Other regions are color-coded by failure type. Simulation was done assuming an inductor Q of 600 and an operating frequency of 1 MHz.

With t_{on} determined, the dc input voltage required to generate the desired V_{pk} is

$$V_{in} = \frac{V_{pk}}{1 + \frac{t_{on}\omega_r}{2}} \quad (2)$$

We then analytically compute the inductor and switch rms currents. The rms inductor current is found to be

$$I_{l,rms} = \sqrt{\frac{V_{in}^2 t_{on}^2}{12TL_r} + \frac{V_{in}^2 t_{on}^2}{16L_r^2}} \quad (3)$$

The rms switch current is also found to be

$$I_{sw,rms} = \sqrt{\frac{V_{in}^2 t_{on}^3}{12TL_r^2}} \quad (4)$$

We then estimate the losses in the FET based on a hypothesis of its dynamic R_{on} and the losses in the inductor based on a hypothesis of its Q ; these hypotheses are subject to error, so the results of the program are understood to be estimates only. Nevertheless, although R_{on} is not known exactly and the achievable Q may not be known *a priori*, multiple plots can be generated for several values of R_{on} and Q to explore the design space.

The color regions are mapped as:

- Green → Acceptable - Passes all constraints
- Red → Device is expected to overheat
- Blue → switch loss P_{sw} does not represent the majority of total loss
- Purple → Intersection of Red and Blue case (i.e. device overheats *and* P_{sw} not majority of loss)

For a given device and frequency, an (L_r, C_r) point is chosen from the acceptable region, sufficiently far from any failure region as the region boundaries are calculated with a hypothesis for dynamic R_{on} . Nevertheless, L_r and C_r can be tuned afterwards to account for assumption errors.

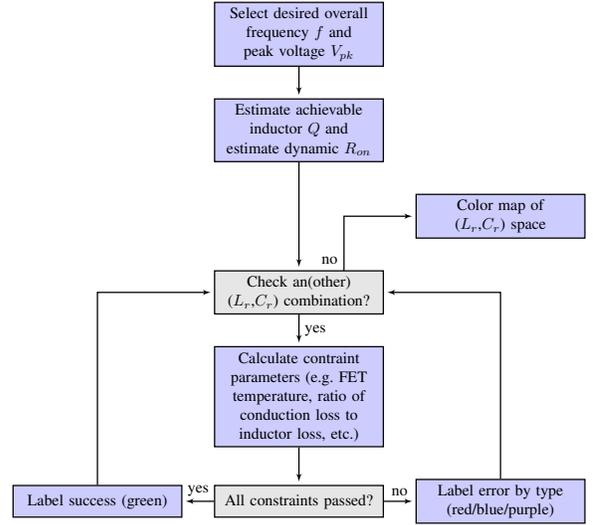


Fig. 14: Flowchart of the program for obtaining a rough estimate of L_r, C_r values. Several inductor Q can be considered, giving the designer a sense of how feasible the inductor implementation stage will be.

After the L_r and C_r values are chosen for a given assumption about the inductor quality factor, it is important that L_r be implemented to achieve at least that quality factor. Since the inductor losses are likely to be substantial, it is also important that its quality factor be well characterized so its losses can be accurately accounted for.

To achieve these features, The resonant inductor is implemented as a large air-core solenoid (Fig. 4) for two reasons. First, air-core solenoids for the 1–10 MHz frequency range can achieve quality factors well above 500. Second, air-core inductors have linear resistance and accurate resistance measurements with an impedance analyzer can be appropriately extrapolated to large-signal conditions.

The design of high- Q air-core solenoids is well understood [23], [24]. A design obtained analytically (e.g. in [24]) can be verified with FEA tools or with available calculators which take into account a number of empirically-determined relationships for air-core solenoids (e.g. [25]). Using this approach, we obtained an inductor with $Q = 680$ at 3 MHz.

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